Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Currently Amended) A semiconductor laser, comprising:

at least one absorbing layer (8) within the laser resonator, said absorbing layer configured to reduce reducing the transmission T_{Res} of the laser radiation (10) in the laser resonator and decrease for the purpose of decreasing the sensitivity of the semiconductor laser to disturbances created by the radiation (9) fed back into the laser resonator.

- 2. (Currently Amended) The semiconductor laser as claimed in claim 1, in which wherein the absorbing layer (8) is situated in a node of a standing wave that forms during operation of the semiconductor laser in the laser resonator.
- 3. (Currently Amended) The semiconductor laser as claimed in claim 1, in which wherein the reflectivity of the mirrors of the resonator and the transmission T_{Res} of the laser radiation during a resonator circulation are set so as to produce a low sensitivity to disturbances for a wide range of possible output powers of the semiconductor laser.
- 4. (Currently amended) The semiconductor laser as claimed in claim 1-in which wherein the semiconductor laser is a single-mode laser.
 - 5. (Currently Amended) The semiconductor laser as claimed in claim 1, in which

wherein the semiconductor laser is a surface emitting semiconductor laser (VCSEL).

- 6. (Currently Amended) The semiconductor laser as claimed in claim 1, in which wherein the semiconductor laser is a surface emitting semiconductor laser with an external resonator (VECSEL).
- 7. (Currently Amended) The semiconductor laser as claimed in claim 6, in which wherein the surface emitting semiconductor laser contains comprises a Bragg mirror (4) and the absorbing layer (8) is contained disposed in said Bragg mirror (4).
- 8. (Currently Amended) The semiconductor laser as claimed in claim 1, in which wherein the absorbing layer (8) is a gallium arsenide layer.
- 9. (Currently Amended) The semiconductor laser as claimed in claim 1, in which wherein the gallium arsenide layer is approximately 20 nm thick.
- 10. (Currently amended) The semiconductor laser as claimed in claim 1, which contains further comprising a plurality of absorbing layers within the laser resonator.
- 11. (Currently Amended) The semiconductor laser as claimed in claim 5, in which wherein the surface emitting semiconductor laser contains comprises a Bragg mirror (4) and the absorbing layer (8) is contained in said Bragg mirror (4).